## 3.15 Electrical, Optical, and Magnetic Materials and Devices Caroline A. Ross Fall Term, 2005

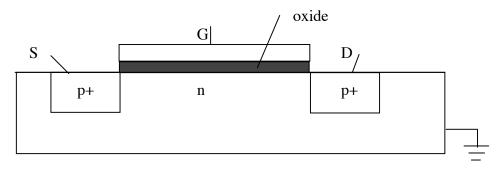
Exam 2 (5 pages)

Closed book exam. Formulae and data are on the last 3.5 pages of the exam. This takes **80 min** and there are 80 points total. Be brief in your answers and use sketches.

Assume everything is at 300K unless otherwise noted.

### 1. MOSFET [20 points]

A MOSFET has the following structure:



- a) What happens when you apply a voltage V<sub>G</sub> to G (when S and D are grounded)? Consider both positive and negative voltages. Illustrate with a sketch of the MOS band diagram. (10)
- b) What happens when you apply a negative voltage  $V_D$  to D, for different values of  $V_G$  (zero, positive and negative)? (assume S is grounded.) Draw plots of current  $I_{SD}$  vs  $V_D$  for different values of  $V_G$ . (10)

### 2. Optics [35 points]

- a) Draw a diagram of the attenuation of a silica optical fiber vs. wavelength, and explain the shape of the curve. (7)
- b) Describe three sources of dispersion in a fiber (one sentence each). (6)
- c) We need to design a system to deliver high power laser light of energy 2 eV via a fiber for surgery inside the body. Would you be concerned with dispersion and loss in this application? (4)
- d) Select materials for the core, cladding and substrate of the 2 eV laser, explaining your choices. If there is more than one option, which would be preferable? (8)

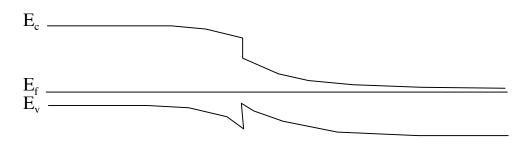
e) It would be nice to have a laser based on Si or  $Si_xGe_{1-x}$  ( $0 \le x \le 1$ ) because this would be compatible with other silicon devices. What colors of light could you expect from a laser made from SiGe? What is the difficulty with making such a laser? How could this be overcome, and what quality output would the laser produce? (Be concise in this question – no more than 5-6 sentences.) (10)

### 3. Heterostructures [25 points]

a) Explain concisely the conditions under which a system can act as laser. (No more than 4-5 sentences). Illustrate by describing a ruby <u>or</u> a Nd-YAG laser. (12)

b) Why is a heterostructure better than a homostructure for making a semiconductor laser? (7)

c) A band diagram of a heterostructure is given below. What can you deduce from this diagram about the doping levels of materials A and B? What has happened to materials A and B near the interface? (6)



Material B

### **Data and Formulae**

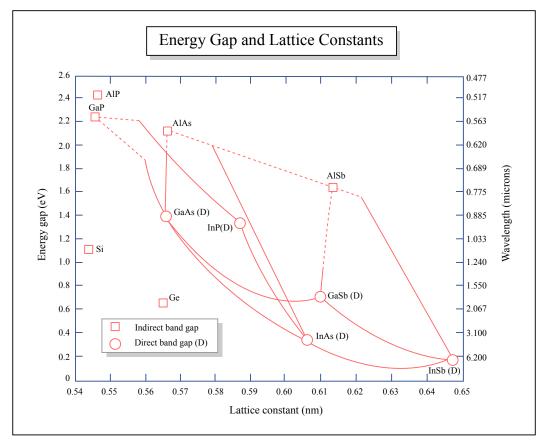


Figure by MIT OCW.

Properties	Si	GaAs	SiO <sub>2</sub>	Ge
Atoms/cm <sup>3</sup> , molecules/cm <sup>3</sup> x 10 <sup>22</sup>	5.0	4.42	2.27 <sup>a</sup>	
Structure	diamond	zincblende	amorphous	
Lattice constant (nm)	0.543	0.565		
Density (g/cm <sup>3</sup> )	2.33	5.32	2.27 <sup>a</sup>	
Relative dielectric constant, $\varepsilon_r$	11.9	13.1	3.9	
Permittivity, $\varepsilon = \varepsilon_r \varepsilon_0 \text{ (farad/cm)} \times 10^{-12}$	1.05	1.16	0.34	
Expansion coefficient (dL/LdT) x (10 <sup>-6</sup> K)	2.6	6.86	0.5	
Specific Heat (joule/g K)	0.7	0.35	1.0	
Thermal conductivity (watt/cm K)	1.48	0.46	0.014	
Thermal diffusivity (cm <sup>2</sup> /sec)	0.9	0.44	0.006	
Energy Gap (eV)	1.12	1.424	~9	0.67
Drift mobility (cm <sup>2</sup> /volt-sec)				
Electrons	1500	8500		
Holes	450	400		
Effective density of states				
$(cm^{-3}) \times 10^{19}$				
Conduction band	2.8	0.047		
Valence band	1.04	0.7		
Intrinsic carrier concentration (cm <sup>-3</sup> )	1.45 x 10 <sup>10</sup>	1.79 x 10 <sup>6</sup>		

Properties of Si, GaAs, SiO2, and Ge at 300 K

Figure by MIT OCW.

Useful equations

 $g_{c}(E) dE = m_{n} * \sqrt{\{2m_{n} * (E - E_{c})\} / (\pi^{2}h^{3})}$ (h = h-bar) $g_v(E) dE = m_p \sqrt{\{2m_p (E_v - E)\}} / (\pi^2 h^3)$  $f(E) = 1/\{1 + \exp(E - E_c)/kT\}$  $p = n_i \exp (E_i - E_f)/kT$  $n = n_i \exp(E_f - E_i)/kT_i$  $n_i = N_c \exp (E_i - E_c)/kT$  where  $N_c = 2\{2\pi m_0 * kT/h^2\}^{3/2}$  $np = n_i^2$  at equilibrium  $n_i^2 = N_c N_v \exp (E_v - E_c)/kT = N_c N_v \exp (-E_v)/kT$  $E_i = (E_v + E_c)/2 + 3/4 \text{ kT} \ln (m_p^{*}/m_n^{*})$  $E_r - E_i = kT \ln (n/n_i) = -kT \ln (p/n_i)$ ~ kT ln  $(N_D / n_i)$  ntype or - kT ln  $(N_A / n_i)$  ptype  $1/2 \text{ mv}^2_{\text{thermal}} = 3/2 \text{ kT}$ Drift: thermal velocity  $\mathbf{E} = \text{field}$ drift velocity  $v_d = \mu E$ Current density (electrons)  $J = n e v_d$ Current density (electrons & holes)  $J = e (n \mu_n + p \mu_h)E$ Conductivity  $\sigma = J/E = e (n \mu_0 + p \mu_b)$  $J = eD_n \nabla n + eD_n \nabla p$ Diffusion Einstein relation:  $D_p/\mu_p = kT/e$ at equilibrium R and G  $R = G = rnp = r n_i^2$  $dn/dt = dn/dt_{drift} + dn/dt_{driftn} + dn/dt_{thermal RO} + dn/dt_{other RO}$  $dn/dt_{diffn} = 1/e \nabla J_{diffn} = D_n d^2 n/dx^2$ Fick's law  $dn/dt = (1/e) \nabla \{J_{drift} + J_{drift}\} + G - R$ so  $dn/dt_{thermal} = -n_l/\tau_n$  or  $dp/dt_{thermal} = -p_l/\tau_p$  $_{n} = \sqrt{\tau_{n}} D_{n}$ , or  $_{n} = \sqrt{\tau_{n}} D_{n}$ .  $\tau_n = 1/rN_A$ , or  $\tau_p = 1/rN_D$ If traps dominate  $\tau = 1/r_2 N_T$  where  $r_2 >> r$ 

#### pn junction

$$\begin{split} \mathbf{E} &= 1/\epsilon_{o}\epsilon_{r}\int\rho(x)\ dx \qquad \text{where }\rho = e(p-n+N_{D}-N_{A})\\ \mathbf{E} &= -dV/dx\\ eV_{o} &= (E_{f}-E_{i})_{n-type} - (E_{f}-E_{i})_{p-type}\\ &= kT/e\ ln\ (n_{n}/n_{p})\ or\ kT/e\ ln\ (N_{A}N_{D}/n_{i}^{\,2})\\ \mathbf{E} &= N_{A}e\ d_{p}/\epsilon_{o}\epsilon_{r} = N_{D}e\ d_{p}/\epsilon_{o}\epsilon_{r} \qquad \text{at }x = 0\\ V_{o} &= (e/2\epsilon_{o}\epsilon_{r})\ (N_{D}d_{n}^{\,2} + N_{A}d_{p}^{\,2})\\ d_{n} &= \sqrt{\{(2\epsilon_{o}\epsilon_{r}V_{o}/e)\ (N_{A}/(N_{D}(N_{D}+N_{A}))\}\}}\\ d &= d_{p} + d_{n} = \sqrt{\{(2\epsilon_{o}\epsilon_{r}(V_{o}+V_{A})/e)\ (N_{D}+N_{A})/N_{A}N_{D}\}}\\ J &= J_{o}\{exp\ eV_{A}/kT - 1\}\ \text{where }J_{o} = en_{i}^{\,2}\ \{D_{p}/N_{D}\Box_{p} + D_{n}/N_{A}\Box_{n}\}\\ \hline \frac{Transistor}{I_{E}} &= (eD_{p}/w)\ (n_{i}^{\,2}/N_{D,B})\ exp(eV_{EB}/kT)\\ JFET &V_{SD,\ sat} = (eN_{D}t^{2}/8\epsilon_{o}\epsilon_{r}) - (V_{o}+V_{G}) \end{split}$$

Photodiode and photovoltaic

 $I = I_o + I_G \qquad V = I (R_{PV} + R_L)$  $I = I_o \{exp \ eV/kT - 1\} + I_G \qquad Power = IV$ 

Wavelength  $\lambda(\mu m) = 1.24/E_g (eV)$ 

Band structure

Effective mass:  $m^* = \hbar^2 (\partial^2 E / \partial k^2)^{-1}$ Momentum of an electron typically  $\pi/a \sim 10^{10} \text{ m}^{-1}$ Momentum of a photon  $= 2\pi/\lambda \sim 10^7 \text{ m}^{-1}$ Uncertainly principle  $\Delta x \Delta p \ge \hbar$ 

Lasers

 $\begin{array}{ll} \mbox{probability of absorption} = B_{13}, \mbox{stimulated emission} = B_{31}, \mbox{spontaneous emission} = A_{31} \\ N_3 = N_1 \mbox{ exp (-hv_{31}/kT)} \\ \mbox{Planck } \rho(\nu) d\nu = \{8\pi h\nu^3/c^3 \}/\{\mbox{exp (hv/kT)} - 1\} \ d\nu \\ B_{13} = B_{31} \\ \mbox{and} \quad A_{31}/B_{31} = 8\pi h\nu^3/c^3 \quad (\mbox{Einstein relations}) \\ \mbox{Cavity modes} \qquad \nu = cN/2d, \ N \ \mbox{an integer}. \end{array}$ 

**Fibers** 

Attenuation (dB) = {10/L} log(P<sub>in</sub>/P<sub>out</sub>) L = fiber length Snell's law: n sin  $\phi$  = n' sin  $\phi$ ' Dispersion coefft. D<sub> $\lambda$ </sub> = -{ $\lambda_o/c$ }( $\partial^2 n/\partial \lambda^2$ )<sub> $\lambda = \lambda_o$ </sub> ps/km.nm  $\sigma_t = \sigma_{\lambda} L D_{\lambda}$ 

# PHYSICAL CONSTANTS, CONVERSIONS, AND USEFUL COMBINATIONS

### **Physical Constants**

Avogadro constant	$N_A = 6.022 \text{ x } 10^{23} \text{ particles/mole}$
Boltzmann constant	$k = 8.617 \text{ x } 10^{-5} \text{ eV/K} = 1.38 \text{ x } 10^{-23} \text{ J/K}$
Elementary charge	$e = 1.602 \text{ x } 10^{-19} \text{ coulomb}$
Planck constant	$h = 4.136 \text{ x } 10^{-15} \text{ eV} \cdot \text{s}$
	$= 6.626 \text{ x } 10^{-34} \text{ joule } \cdot \text{s}$
Speed of light	$c = 2.998 \text{ x } 10^{10} \text{ cm/s}$
Permittivity (free space)	$\varepsilon_0 = 8.85 \text{ x } 10^{-14} \text{ farad/cm}$
Electron mass	$m = 9.1095 \text{ x } 10^{-31} \text{ kg}$
Coulomb constant	$k_{\rm c} = 8.988 \text{ x } 10^9 \text{ newton-m}^2/(\text{coulomb})^2$
Atomic mass unit	$u = 1.6606 \text{ x } 10^{-27} \text{ kg}$
	e

## Useful Combinations

Thermal energy (300 K)	$kT = 0.0258 \text{ eV} \approx 1 \text{ eV}/40$
Photon energy	$E = 1.24 \text{ eV}$ at $\lambda = \mu \text{m}$
Coulomb constant	$k_{\rm c} {\rm e}^2$ 1.44 eV · nm
Permittivity (Si)	$\varepsilon = \varepsilon_r \varepsilon_0 = 1.05 \text{ x } 10^{-12} \text{ farad/cm}$
Permittivity (free space)	$\varepsilon_0 = 55.3 \text{e/V} \cdot \mu \text{m}$

## Prefixes

k = kilo =  $10^3$ ; M = mega =  $10^6$ ; G = giga =  $10^9$ ; T = tera =  $10^{12}$ m = milli =  $10^{-3}$ ;  $\mu$  = micro =  $10^{-6}$ ; n = nano =  $10^{-9}$ ; p = pica =  $10^{-12}$ 

## Symbols for Units

Ampere (A), Coulomb (C), Farad (F), Gram (g), Joule (J), Kelvin (K) Meter (m), Newton (N), Ohm ( $\Omega$ ), Second (s), Siemen (S), Tesla (T)

Volt (V), Watt (W), Weber (Wb)

## Conversions

1 nm =  $10^{-9}$  m = 10 Å =  $10^{-7}$  cm; 1 eV =  $1.602 \times 10^{-9}$  Joule =  $1.602 \times 10^{-12}$  erg; 1 eV/particle = 23.06 kcal/mol; 1 newton = 0.102 kg<sub>force</sub>; 10<sup>6</sup> newton/m<sup>2</sup> = 146 psi =  $10^{7}$  dyn/cm<sup>2</sup>; 1 µm =  $10^{-4}$  cm 0.001 inch = 1 mil = 25.4 µm; 1 bar =  $10^{6}$  dyn/cm<sup>2</sup> =  $10^{5}$  N/m<sup>2</sup>; 1 weber/m<sup>2</sup> =  $10^{4}$  gauss = 1 tesla; 1 pascal = 1 N/m<sup>2</sup> =  $7.5 \times 10^{-3}$  torr; 1 erg =  $10^{-7}$  joule = 1 dyn-cm

Figure by MIT OCW.